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| Notice of References Cited | | Application/Control No. | Applicant(s)/Patent Under Reexamination | |
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| | | Examiner | Art Unit | |
| | | Fernando L. Toledo | 2823 | Page 1 of 1 |

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| * | | Document Number Country Code-Number-Kind Code | Date MM-YYYY | Name | Classification |
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| | D | US- | | | |
| | E | US- | | | |
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FOREIGN PATENT DOCUMENTS

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NON-PATENT DOCUMENTS

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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
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